

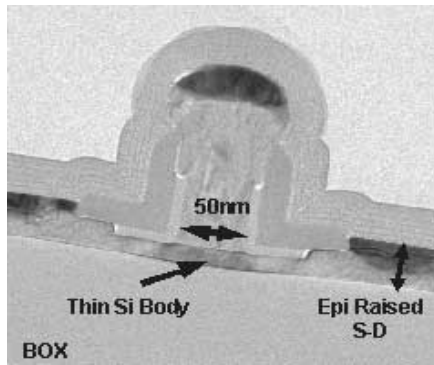
# Nano-Scale Device Simulations Using PROPHET Part I: Basics

Yang Liu

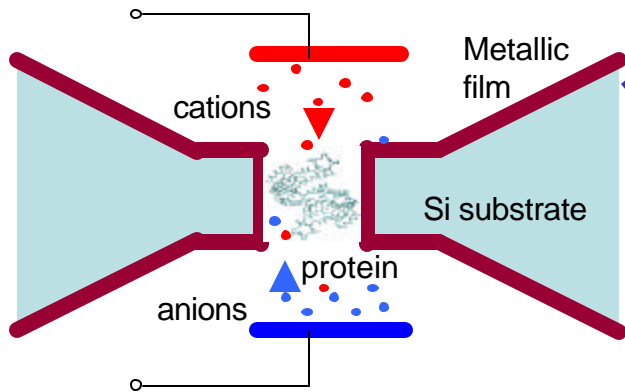
TCAD Group, Stanford University

Dec. 2005

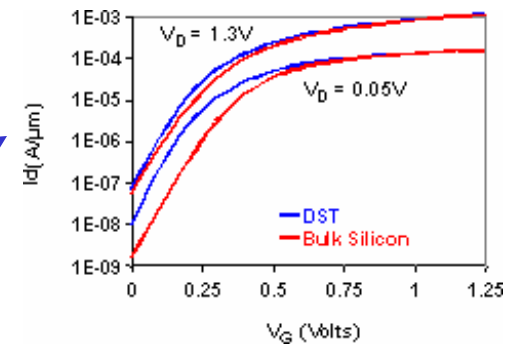
# Nano-scale devices & modeling



(Intel, 2002)

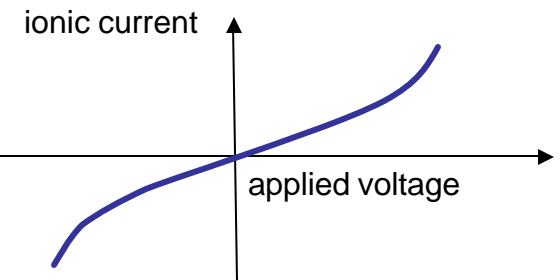


Semiconductor devices



Device modeling & simulation

Nano-bio devices

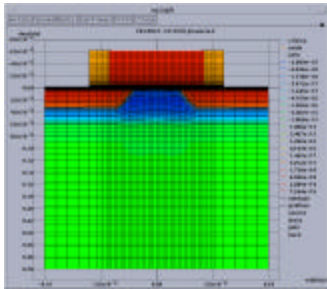


Simulated output to be compared with measurements

## Modeling & Simulation Approach

- Establish device equations (e.g. continuum-based partial differential equations)
- Discretize PDEs into difference equations
- Solve difference equations (usually nonlinear)
- Post-process; interpret simulation results

# Example: simulation of a transistor



Device structure

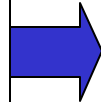
$$\frac{\partial n(\vec{r})}{\partial t} = \frac{1}{q} \nabla \cdot \vec{J}_n(\vec{r}) - U_n(\vec{r})$$

$$\frac{\partial p(\vec{r})}{\partial t} = -\frac{1}{q} \nabla \cdot \vec{J}_p(\vec{r}) - U_p(\vec{r})$$

$$\nabla \cdot \epsilon(\vec{r}) \nabla \psi(\vec{r}) + q(p(\vec{r}) - n(\vec{r}) + N_d(\vec{r}) - N_a(\vec{r})) = 0$$

Shockley Eqns.

**MODEL EQNS.**



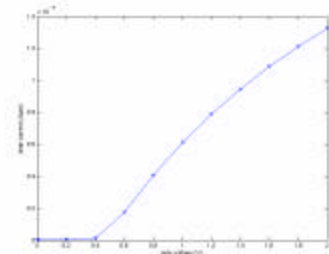
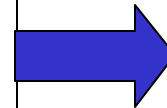
$$\begin{pmatrix} \vec{F}_1(\vec{y}, \vec{n}, \vec{p}) \\ \vec{F}_2(\vec{y}, \vec{n}, \vec{p}) \\ \vec{F}_3(\vec{y}, \vec{n}, \vec{p}) \end{pmatrix} = 0$$

Nonlinear difference eqns.

$$\begin{pmatrix} \frac{\partial \vec{F}_1}{\partial \vec{\psi}} & \frac{\partial \vec{F}_1}{\partial \vec{n}} & \frac{\partial \vec{F}_1}{\partial \vec{p}} \\ \frac{\partial \vec{F}_2}{\partial \vec{\psi}} & \frac{\partial \vec{F}_2}{\partial \vec{n}} & \frac{\partial \vec{F}_2}{\partial \vec{p}} \\ \frac{\partial \vec{F}_3}{\partial \vec{\psi}} & \frac{\partial \vec{F}_3}{\partial \vec{n}} & \frac{\partial \vec{F}_3}{\partial \vec{p}} \end{pmatrix}_{k-1} \begin{pmatrix} \vec{\psi}_k - \vec{\psi}_{k-1} \\ \vec{n}_k - \vec{n}_{k-1} \\ \vec{p}_k - \vec{p}_{k-1} \end{pmatrix} = \begin{pmatrix} \vec{F}_1(\vec{\psi}_{k-1}, \vec{n}_{k-1}, \vec{p}_{k-1}) \\ \vec{F}_2(\vec{\psi}_{k-1}, \vec{n}_{k-1}, \vec{p}_{k-1}) \\ \vec{F}_3(\vec{\psi}_{k-1}, \vec{n}_{k-1}, \vec{p}_{k-1}) \end{pmatrix}$$

Newton method

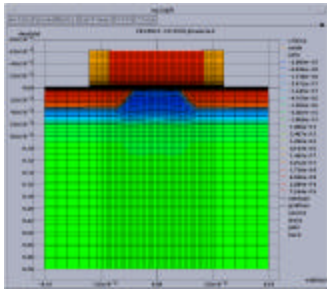
**DISCRETIZATION/  
NUMERICS**



Id-Vg output

**OUTPUT**

# Example: simulation of a transistor



Device structure

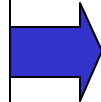
$$\frac{\partial n(\vec{r})}{\partial t} = \frac{1}{q} \nabla \cdot \vec{J}_n(\vec{r}) - U_n(\vec{r})$$

$$\frac{\partial p(\vec{r})}{\partial t} = -\frac{1}{q} \nabla \cdot \vec{J}_p(\vec{r}) - U_p(\vec{r})$$

$$\nabla \cdot \epsilon(\vec{r}) \nabla \psi(\vec{r}) + q(p(\vec{r}) - n(\vec{r}) + N_d(\vec{r}) - N_a(\vec{r})) = 0$$

Shockley Eqns.

**MODEL EQNS.**



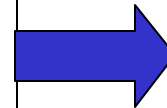
$$\begin{pmatrix} \bar{F}_1(\vec{y}, \vec{n}, \vec{p}) \\ \bar{F}_2(\vec{y}, \vec{n}, \vec{p}) \\ \bar{F}_3(\vec{y}, \vec{n}, \vec{p}) \end{pmatrix} = 0$$

Nonlinear difference eqns.

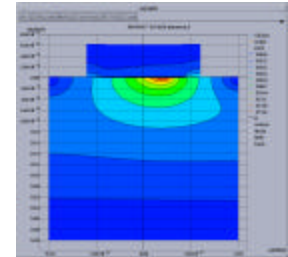
$$\begin{pmatrix} \frac{\partial \bar{F}_1}{\partial \vec{\psi}} & \frac{\partial \bar{F}_1}{\partial \vec{n}} & \frac{\partial \bar{F}_1}{\partial \vec{p}} \\ \frac{\partial \bar{F}_2}{\partial \vec{\psi}} & \frac{\partial \bar{F}_2}{\partial \vec{n}} & \frac{\partial \bar{F}_2}{\partial \vec{p}} \\ \frac{\partial \bar{F}_3}{\partial \vec{\psi}} & \frac{\partial \bar{F}_3}{\partial \vec{n}} & \frac{\partial \bar{F}_3}{\partial \vec{p}} \end{pmatrix}_{k-1} \cdot \begin{pmatrix} \vec{\psi}_k - \vec{\psi}_{k-1} \\ \vec{n}_k - \vec{n}_{k-1} \\ \vec{p}_k - \vec{p}_{k-1} \end{pmatrix} = \begin{pmatrix} \bar{F}_1(\vec{\psi}_{k-1}, \vec{n}_{k-1}, \vec{p}_{k-1}) \\ \bar{F}_2(\vec{\psi}_{k-1}, \vec{n}_{k-1}, \vec{p}_{k-1}) \\ \bar{F}_3(\vec{\psi}_{k-1}, \vec{n}_{k-1}, \vec{p}_{k-1}) \end{pmatrix}$$

Newton method

**DISCRETIZATION/  
NUMERICS**



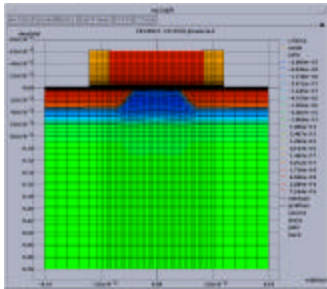
What if model improvement is needed?



temp. distribution

**OUTPUT**

# Example: simulation of a transistor



Device structure

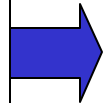
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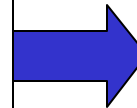
$$\nabla \cdot \epsilon(\vec{r}) \nabla \psi(\vec{r}) + q(p(\vec{r}) - n(\vec{r}) + N_d(\vec{r}) - N_a(\vec{r})) = 0$$

Shockley Eqns.

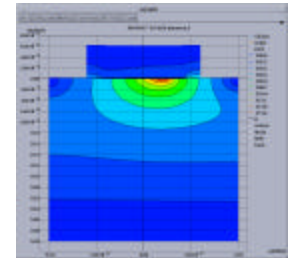
**MODEL EQNS.**



**PROPHET:  
DISCRETIZATION/  
NUMERICS MADE  
TRANSPARENT!**



What if model improvement is needed?



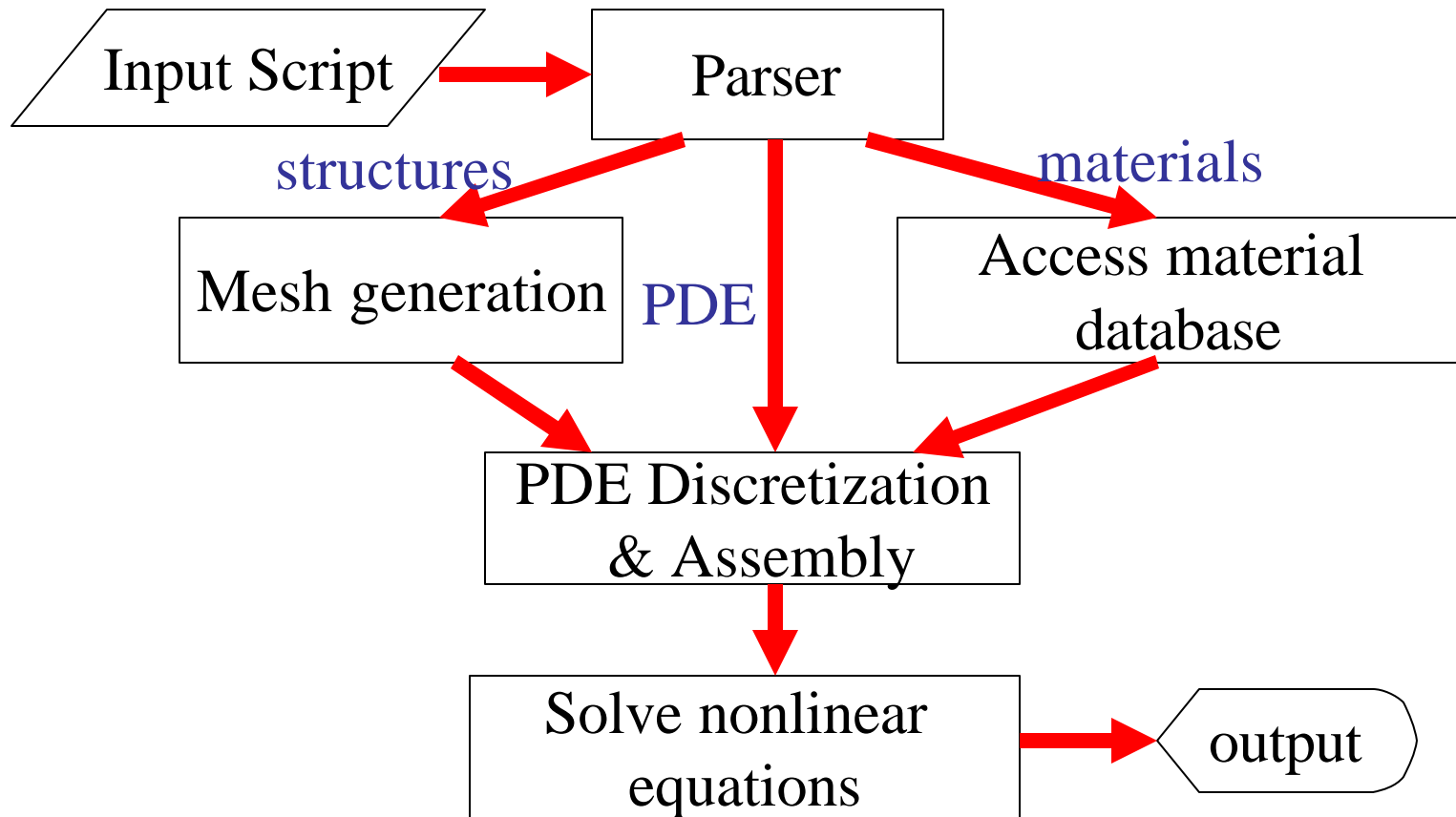
temp. distribution

**OUTPUT**

## Introduction to PROPHET

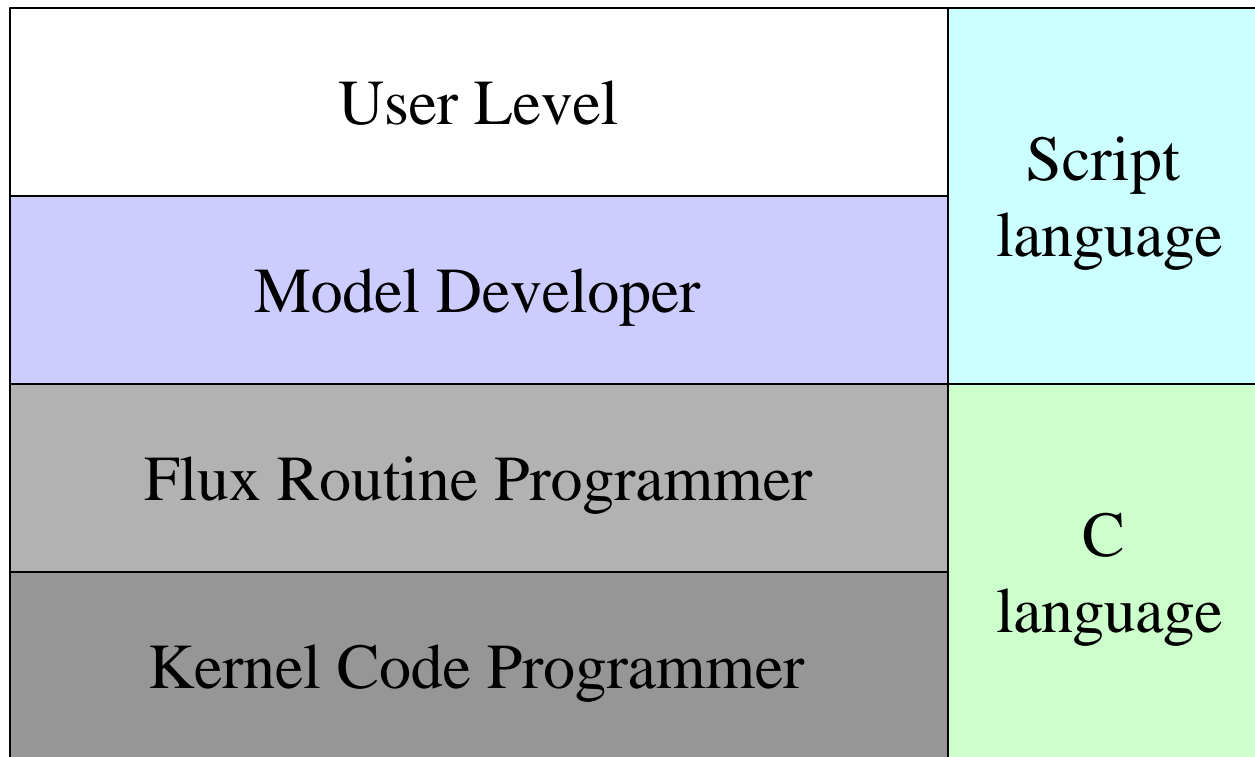
- PROPHET: a general PDE solver; suitable for continuum-based simulations of semiconductor and nano-bio devices
- Comparison with other numerical tools
  - Specialized semiconductor simulators
  - Matlab, Mathematica
- Link:  
[http://www.nanohub.org/resource\\_files/tools/prophet/doc/guide.html](http://www.nanohub.org/resource_files/tools/prophet/doc/guide.html)

# PROPHET simulation flowchart





# PROPHET Hierarchical Programming



## Introduction to PDEs

- Elliptic

- Poisson eqn.  $\mathbf{e}\nabla^2 u = \mathbf{e}\left(\frac{\partial^2 u}{\partial x^2} + \frac{\partial^2 u}{\partial y^2} + \frac{\partial^2 u}{\partial z^2}\right) = C(x, y, z)$

- Parabolic

- Diffusion eqn.  $\frac{\partial u}{\partial t} = D\nabla^2 u = D\left(\frac{\partial^2 u}{\partial x^2} + \frac{\partial^2 u}{\partial y^2} + \frac{\partial^2 u}{\partial z^2}\right)$

- Hyperbolic

- Drift eqn.  $\frac{\partial u}{\partial t} = \vec{v} \cdot \nabla u = v_x \frac{\partial u}{\partial x} + v_y \frac{\partial u}{\partial y} + v_z \frac{\partial u}{\partial z}$

- Wave eqn.  $\frac{\partial^2 u}{\partial t^2} = c^2 \nabla^2 u = c^2 \left(\frac{\partial^2 u}{\partial x^2} + \frac{\partial^2 u}{\partial y^2} + \frac{\partial^2 u}{\partial z^2}\right)$

## Example: 1-D Poisson Equation

- Solve potential  $u(x)$  for known charge distribution  $C(x)$

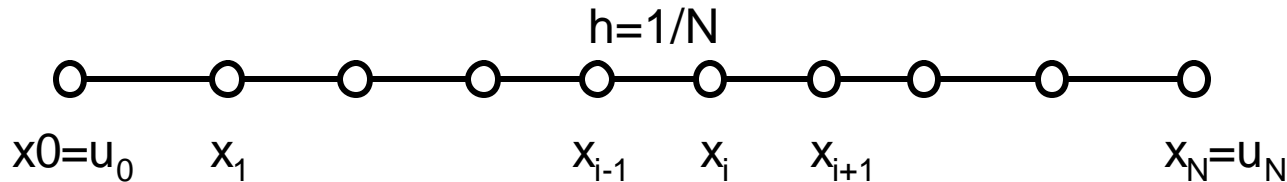
$$\partial^2 u(x) / \partial x^2 = C(x)$$

- Dirichlet boundary condition:  $u|_{x=0}=u_0$ ;  $u|_{x=1}=u_N$
- Analytical solution for constant  $C(x)=C_0$

$$u(x) = \frac{C_0}{2} x^2 + \left( u_N - u_0 - \frac{C_0}{2} \right) x + u_0$$

## Numerically solve 1-D Poisson Eqn.

- Partition domain  $x=[0,1]$  into  $N$  sub-domains:



- Discretize Poisson eq. into difference eqs.:

$$\left. \frac{\partial^2 u}{\partial x^2} \right|_{x=x_i} = \frac{u_{i-1} + u_{i+1} - 2u_i}{h^2} + O(h^2) \approx \frac{u_{i-1} + u_{i+1} - 2u_i}{h^2}$$



# PROPHET for 1-D Poisson Eq.

Part 1 of PROPHET script “poisson1d.pf”

```
#create dbase entry for sysvar u
dbase createlist name=library/physics/silicon/u
dbase prefix=library/physics/silicon/u
dbase create name=dirichlet.contact0 rval=0.0
dbase create name=dirichlet.contact1 rval=1.0
dbase create name=scale rval=1.0
dbase create name=Dix rval=1
dbase prefix=""

#define system poisson
system name=poisson
+ sysvars=u
+ term0=box_div.lapflux(u|u)@{silicon}
+ term1=nodal.copy(c|u)@{silicon}
+ term2=dirichlet.default_dirichlet(0|u)@{silicon/contact0,silicon/contact1}
```

# PROPHET for 1-D Poisson Eq.

Part 2 of PROPHET script “poisson1d.pf”

```
#define simulation mesh and boundaries
grid xloc=0,1 xdel=0.005 dim=1
boundary xmin=0 xmax=0 name=contact0
boundary xmin=1 xmax=1 name=contact1

#define fixed charge
field set=c val=5
#initialize sysvar u
field set=u val=0

#solve and plot
solve system=poisson
graph quantity=u
exit
```

# PROPHET for 1-D Poisson Eq.

## Output of PROPHET script "poisson1d.pf"

```

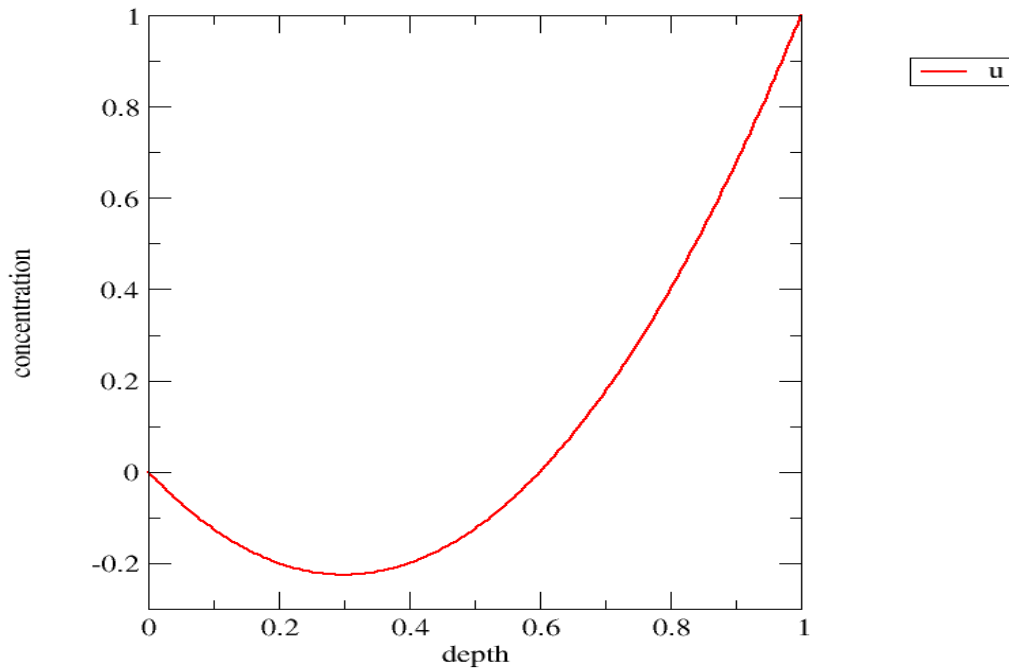
8 system  cpu:  0.25 sec 0r 0i  0n  0e [2704k]
-----
Tensor_mesh: dim = 1
Creating tensor mesh: 201 = 201 nodes
9 grid  cpu:  0.26 sec 1r 3i  201n  200e [2744k]
-----
contact0: 1 elements matched by boundary specification
10 boundary  cpu:  0.26 sec 1r 4i  201n  200e [2752k]
-----
contact1: 1 elements matched by boundary specification
11 boundary  cpu:  0.26 sec 1r 5i  201n  200e [2760k]
-----
12 field  cpu:  0.26 sec 1r 5i  201n  200e [2768k]
-----
13 field  cpu:  0.26 sec 1r 5i  201n  200e [2776k]
-----
Starting Newton iterations:
solving for: u
(linear eq. solver: direct, package: petsc)
Newton iter 0      0.983u  0.5n  0.005lg  0.005lr
Newton iter 1      2.03e-14u 4.85e-16n 4.85e-18lg 4.85e-18lr
Newton converged:  residual norm = 3.24e-16n, reduction = 6.49e-16
                  cpu = 0.02 sec
14 solve  cpu:  0.30 sec 1r 5i  201n  200e [2912k]

```



# PROPHET for 1-D Poisson Eq.

PROPHET-SU 9910

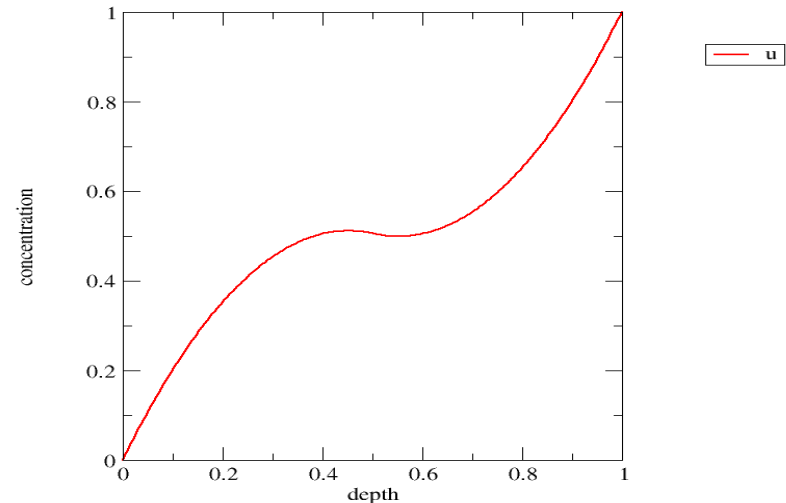
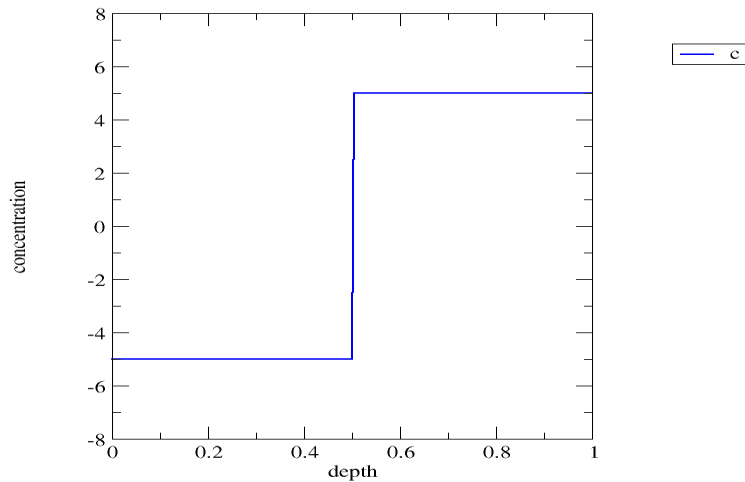


Simulated  $u(x)$  from PROPHET script “poisson1d.pf”

# PROPHET for 1-D Poisson Eq.

Simulate for different  $C(x)$ . Only need to change:

```
#define fixed charge  
field set=c1 val=-5 xrange=[0:0.5]  
field set=c2 val=5 xrange=(0.5:1)  
field set=c val=c1+c2
```



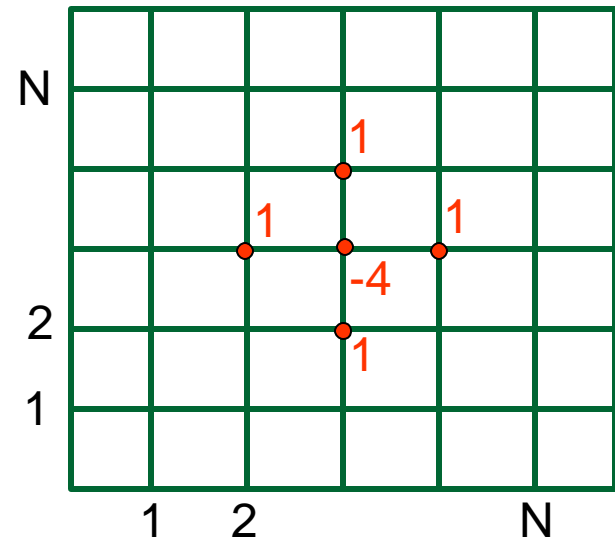
# Numerically Solve 2-D Poisson Eq.

- 2-D Poisson eq:

$$\partial^2 u(x, y) / \partial x^2 + \partial^2 u(x, y) / \partial y^2 = C(x, y)$$

- 5-point discretization method

$$\nabla^2 u \approx \frac{u_{i-1,j} + u_{i+1,j} + u_{i,j-1} + u_{i,j+1} - 4u_{i,j}}{h^2}$$





# PROPHET for 2-D Poisson Eq.

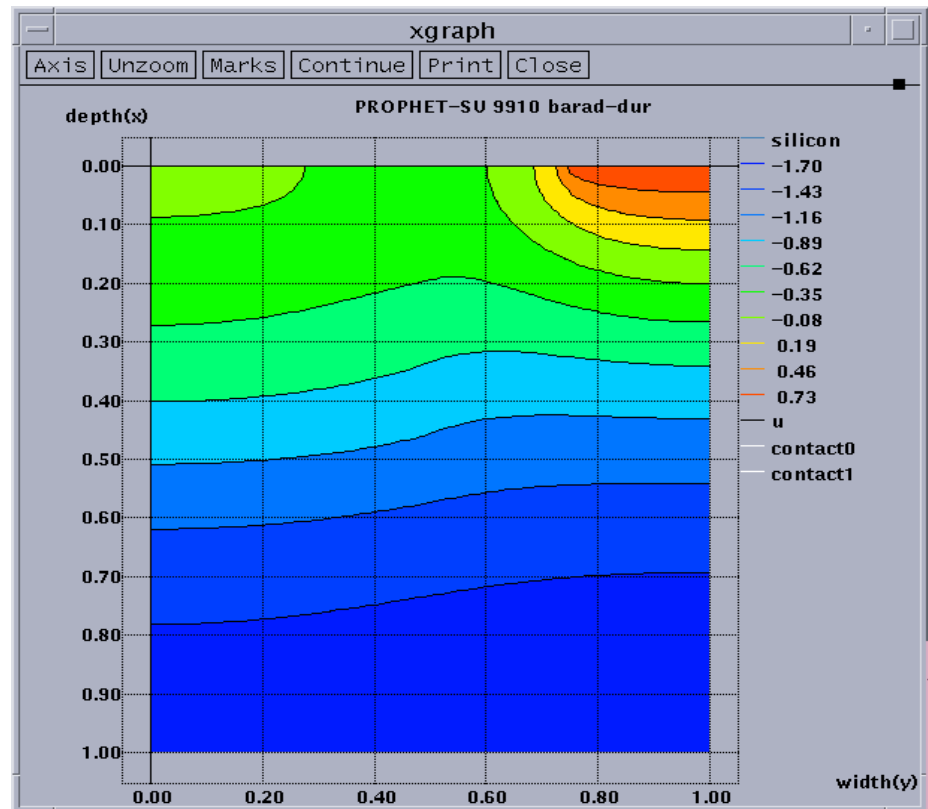
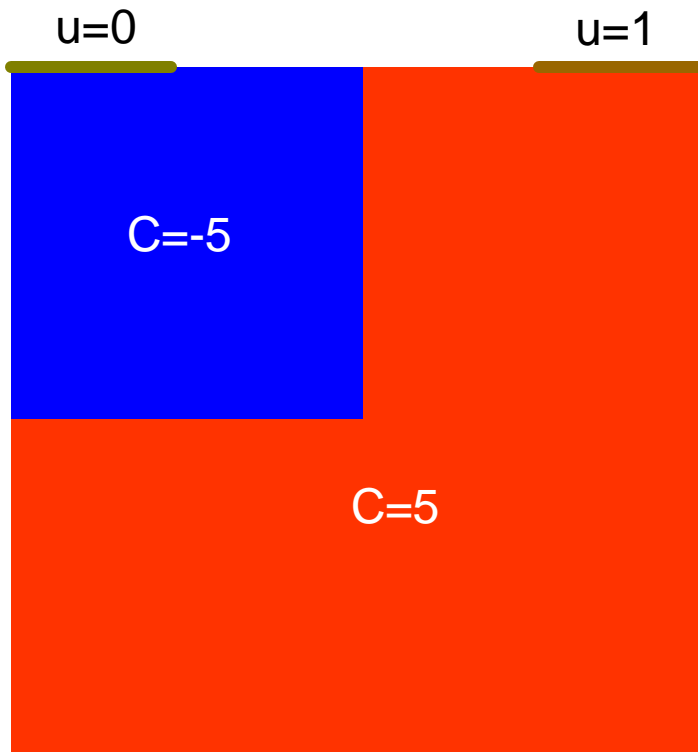
Part 2 of PROPHET script “poisson2d.pf”

```
#define simulation mesh and boundaries
grid xloc=0,1 xdel=0.02 yloc=0,1 ydel=0.02 dim=2
boundary xmin=0 xmax=0 ymin=0 ymax=0.25 name=contact0
boundary xmin=0 xmax=0 ymin=0.75 ymax=1 name=contact1

#define fixed charge
field set=c1 val=5
field set=c2 val=-10 xrange=[0:0.5] yrange=[0:0.5]
field set=c val=c1+c2
#initialize sysvar u
field set=u val=0

#solve and plot
solve system=poisson
graph quantity=u contour color
```

# PROPHET for 2-D Poisson Eq.



$u(x)$  simulated with PROPHET

# PROPHET command syntax

- General command format

```
Command_name keyword=value keyword=value ...  
Keyword value types: logical, real, integer, string ...
```

- Examples:

```
bias system=silicon_dd nstep=5 vstep=0.1 elec=anode  
field set=c val=5 xrange=[0:0.1]  
dbase create name=library/physics/silicon/psi/Dix rval=8.85e-14
```

- Notice that:

- Lines that start with “#” are comments
- Long lines can be broken using “+” as connectors

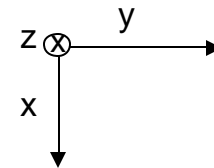
# PROPHET command syntax

- Keyword value types:
  - logical: true (“t”, “1” or by default)/false (“f” or “0”)
  - real: floating point value (140.0, 140 or 1.4e2; expressions are allowed)
  - real array: separated by commas (“0,0.01,0.1,1”)
  - integer and integer array
  - string: string of characters (system=silicon\_dd)
  - string array: array of strings (elec=gate,drain)



## PROPHET command: GRID

- **GRID**: generates a 1D/2D/3D rectilinear grid
  - **xloc/yloc**: real arrays that define grid segments
  - **xdel/ydel**: grid size for each segment
  - **dim**: grid dimension
  - **material**: region material



- **Examples**

```
grid dim=1 xloc=0,0.05,1 xdel=0.005,0.01,0.1 mat=silicon
```

```
grid dim=2 xloc=0,0.05,1 xdel=0.005,0.01,0.1  
+ yloc=0,0.5,1 ydel=0.05,0.05,0.1 mat=silicon
```

## PROPHET command: DEPOSIT

- Add a material layer onto existing structure
  - **thickness**: thickness of deposited layer
  - **xdel**: grid size of deposited layer
  - **start/end**: define area of selective deposition
  - **material**:
- Examples:

```
deposit mat=oxide thick=0.002 xdel=0.002 #Gate oxide
```

```
deposit mat=poly start=-0.03 end=0.03 thick=0.0,0.1 xdel=0.002,0.05 #poly gate
```

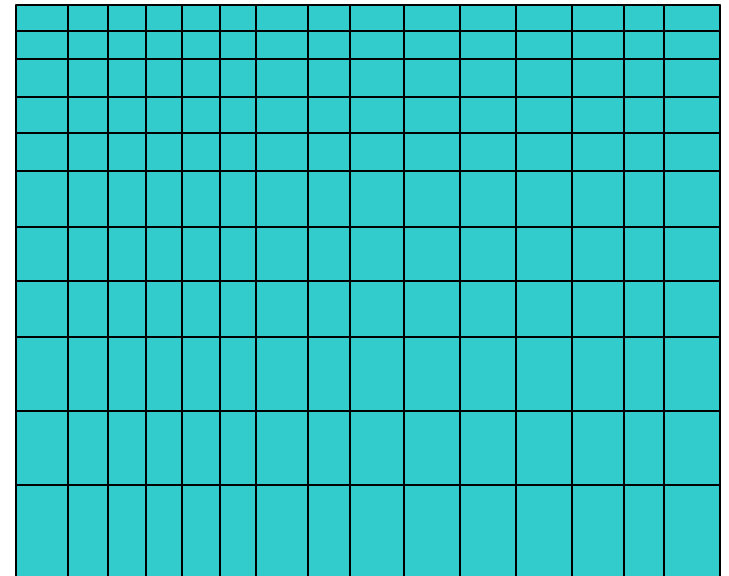
```
deposit mat=oxide start=-0.05 end=-0.03 thick=0.0,0.1 xdel=0.002,0.05 #spacer
```

```
deposit mat=oxide start=0.03 end=0.05 thick=0.0,0.1 xdel=0.002,0.05 zipper
```

# Example: GRID/DEPOSIT

PROPHET script “deposit(pf)”

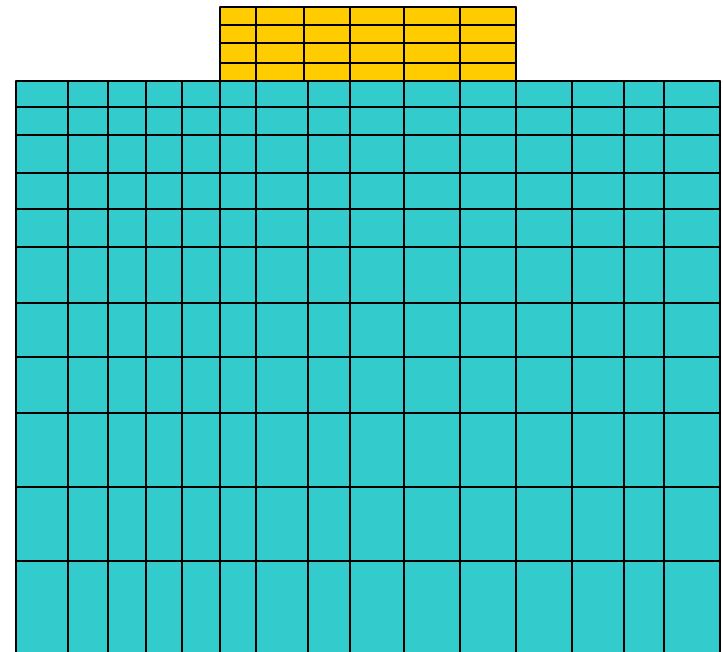
```
#substrate  
grid dim=2 xloc=0,0.1,1 xdel=0.01,0.02,0.1  
+ yloc=0,1 ydel=0.1 mat=silicon
```



# Example: GRID/DEPOSIT

PROPHET script “deposit(pf)”

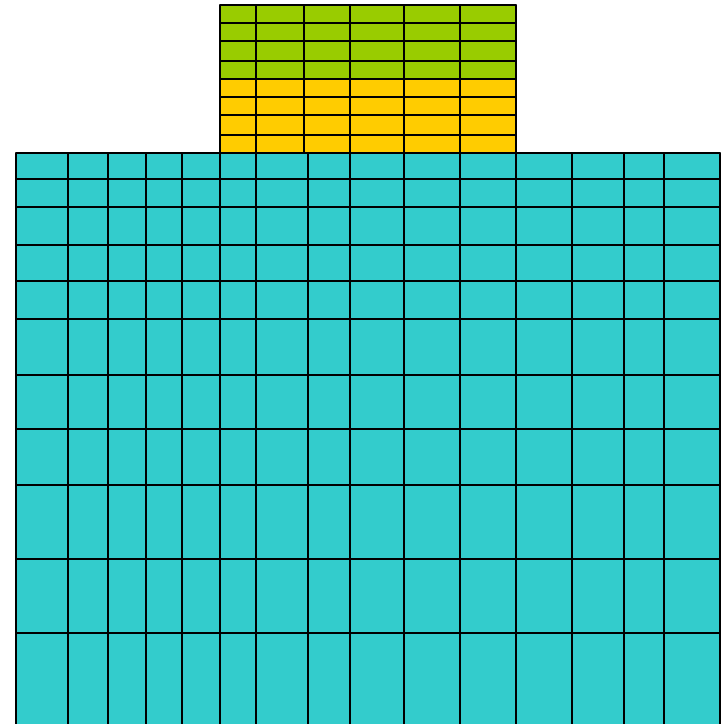
```
#substrate
grid dim=2 xloc=0,0.1,1 xdel=0.01,0.02,0.1
+ yloc=0,1 ydel=0.1 mat=silicon
#gate oxide
deposit thick=0.1 xdel=0.01
+ mat=oxide start=0.3 end=0.7
```



# Example: GRID/DEPOSIT

PROPHET script “deposit(pf)”

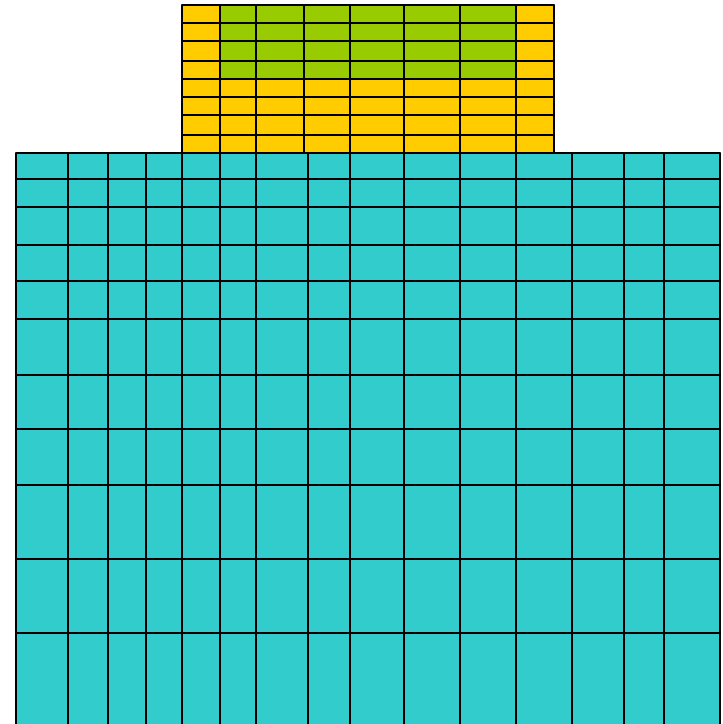
```
#substrate
grid dim=2 xloc=0,0.1,1 xdel=0.01,0.02,0.1
+ yloc=0,1 ydel=0.1 mat=silicon
#gate oxide
deposit thick=0.1 xdel=0.01
+ mat=oxide start=0.3 end=0.7
#poly gate
deposit thick=0.1 xdel=0.01
+ mat=poly start=0.3 end=0.7
```



# Example: GRID/DEPOSIT

PROPHET script “deposit(pf)”

```
#substrate
grid dim=2 xloc=0,0.1,1 xdel=0.01,0.02,0.1
+ yloc=0,1 ydel=0.1 mat=silicon
#gate oxide
deposit thick=0.1 xdel=0.01
+ mat=oxide start=0.3 end=0.7
#poly gate
deposit thick=0.1 xdel=0.01
+ mat=poly start=0.3 end=0.7
#spacer oxide
deposit thick=0.2 xdel=0.01
+ mat=oxide start=0.25 end=0.3
deposit thick=0.2 xdel=0.01 mat=oxide
+ start=0.7 end=0.75 zipper
```



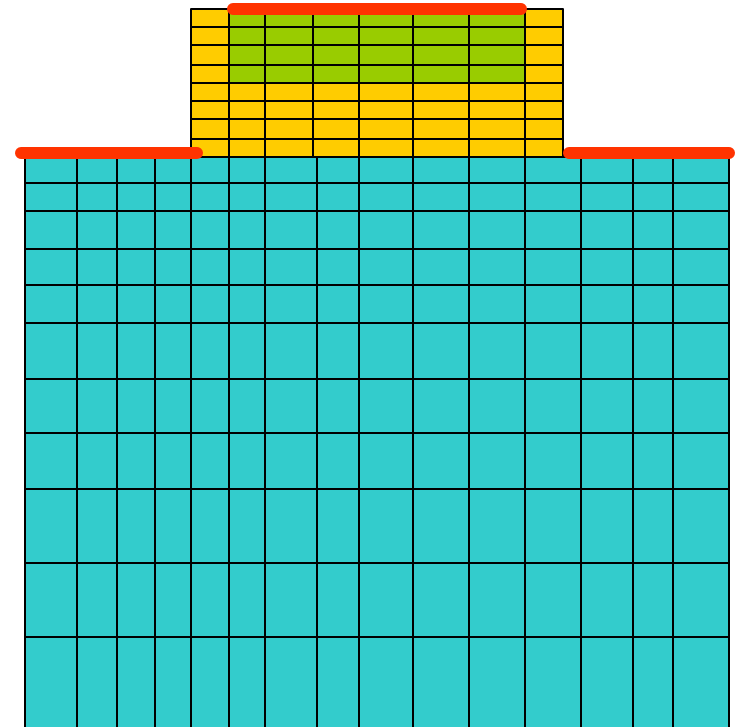
# PROPHET command: BOUNDARY

- Define device contacts

- `xmin/ymin,xmax/ymax`
- `name, material, ...`

- Example

```
#define source/drain contacts  
boundary xmin=0 xmax=0 ymin=0.0  
+ ymax=0.25 name=source  
boundary xmin=0 xmax=0 ymin=0.75  
+ ymax=1.0 name=drain  
#define gate contact  
boundary xmin=-0.2 xmax=-0.2 ymin=0.3  
+ ymax=0.7 name=gate
```



## PROPHET command: FIELD

- Defines various fields over existing grids
  - **set**: name of the field
  - **material**: limit field definition to certain materials
  - **value**: an expression evaluated across grids; can include constants, other fields, coordinates (X,Y,Z upper case). Example:

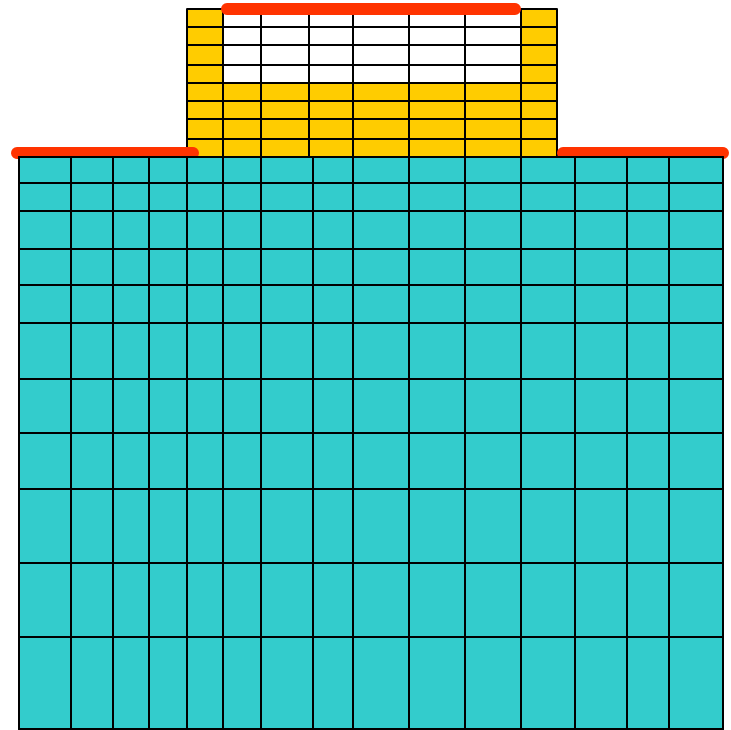
```
field set=c val=5*gbox(X,0,1,0.01)*gbox(Y,1,2,0.01)
```

specifies a flat profile of 5 inside the interval (X,Y)=(0~1,1~2) with Gaussian decay of characteristic length 0.01 outside



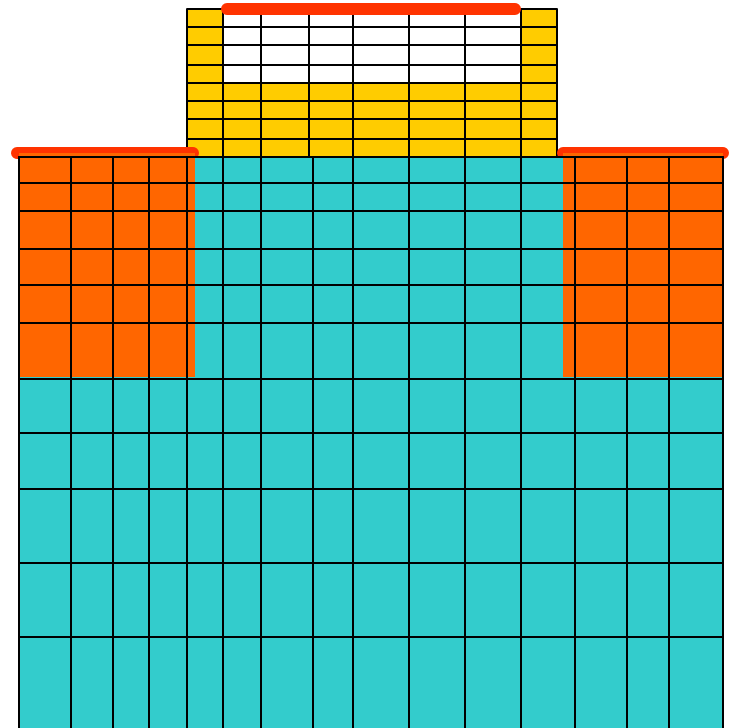
# Example: FIELD

```
#p-substrate  
field set=psub val=-1 mat=silicon
```



## Example: FIELD

```
#p-substrate  
field set=psub val=-1 mat=silicon  
  
#n-diffusion at source/drain  
field set=ns mat=silicon  
+ val=6*gbox(X,0,0.3,0.01)*gbox(Y,0,0.25,0.01)  
  
field set=nd mat=silicon  
+ val=6*gbox(X,0,0.3,0.01)*gbox(Y,0.75,1,0.01)
```



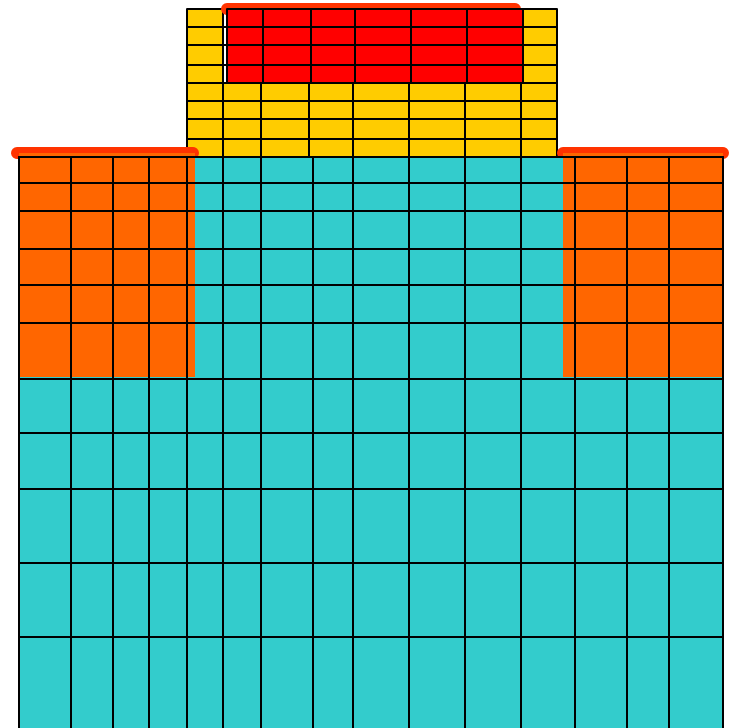
# Example: FIELD

```
#p-substrate
field set=psub val=-1 mat=silicon

#n-diffusion at source/drain
field set=ns mat=silicon
+ val=6*gbox(X,0,0.3,0.01)*gbox(Y,0,0.25,0.01)
field set=nd mat=silicon
+ val=6*gbox(X,0,0.3,0.01)*gbox(Y,0.75,1,0.01)

#n-poly
field set=npoly val=11 mat=poly

#total
field set=c val=psub+ns+nd+poly
```



## PROPHET command: SOLVE/BIAS

- **SOLVE**: solves steady-state/transient PDEs

- **system, seconds, ...**

```
solve system=my_diffusion seconds=0.01
```

- **BIAS**: more features for pre-defined PDEs

- **system, init, electrode, nstep, voltage, vstep, time**

```
bias system=silicon_poisson init  
bias system=silicon_dd elec=anode voltage=0.5  
bias system=silicon_dd elec=gate vstep=0.1 nstep=20  
bias system=silicon_dd elec=gate voltage=1.0 time=1e-6
```

## PROPHET command SAVE/LOAD/GRAPH

- **SAVE/LOAD** in PROPHET native format

```
save pas=my_res1.pas  
load pas=my_res1.pas
```

- **GRAPH**: visualize simulation results

- **quantity, xpos, ypos, xmin, xmax, region, contour, color, gridline, iv, print, outfile**

```
graph quantity=psi ypos=0.0 xmin=-1.0 xmax=1  
graph quantity=netdope contour color  
graph quantity=gridline  
graph quantity=electrons xpos=0.5 print outfile=electrons.txt
```

## Conclusion

- General introduction to device simulations and PROPHET
- Getting started with PROPHET: examples of Poisson equation
- PROPHET command syntax: grid, deposit, field, boundary, solve, bias, save, load, graph

# PROPHET Roadmap

- Lect. #1: basics →
  - Problem set
    - Description in Breeze Lab #1
    - Access through nanoHUB
- Lect. #2: PDE def. ↗
- Advanced topics
  - Nano-bio devices
  - Nano-wire devices
  - Organic semiconductor nano-devices
  - <http://www.nanohub.org>

